



JFW AF/2822

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:

Jack Hwang et al.

Serial No.: 10/644,417

Filed: August 20, 2003

For: Forming Strained Source Drain  
Junction Field Effect Transistors

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Art Unit: 2822

Examiner: Mark V. Prenty

Docket: ITL.0764D1US  
P14416D

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Mail Stop AF  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**REPLY TO FINAL REJECTION**

Sir:

In response to the final rejection mailed August 26, 2004, please amend the above-referenced patent application as follows:

Date of Deposit: September 17, 2004

I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

*Cynthia L. Hayden*  
Cynthia L. Hayden